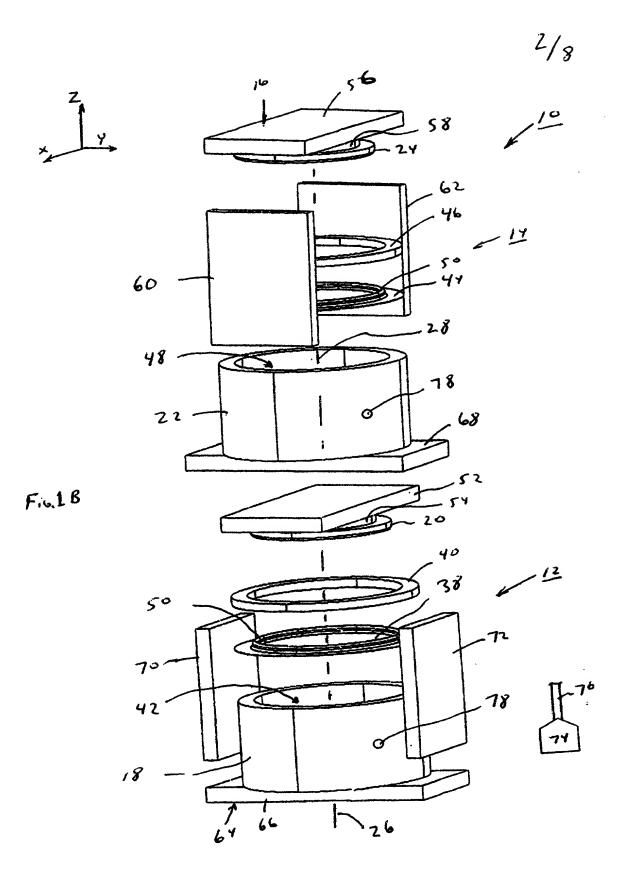


Fig. 1A



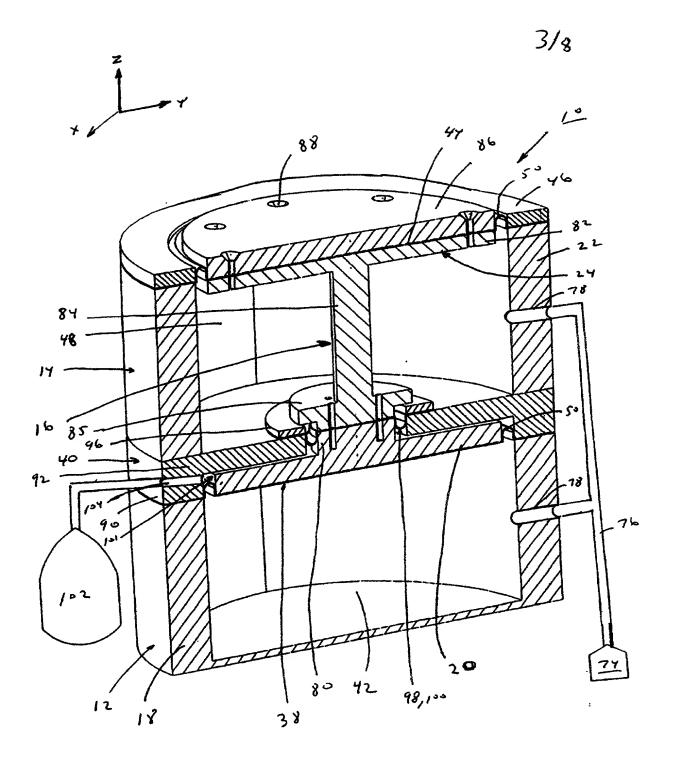
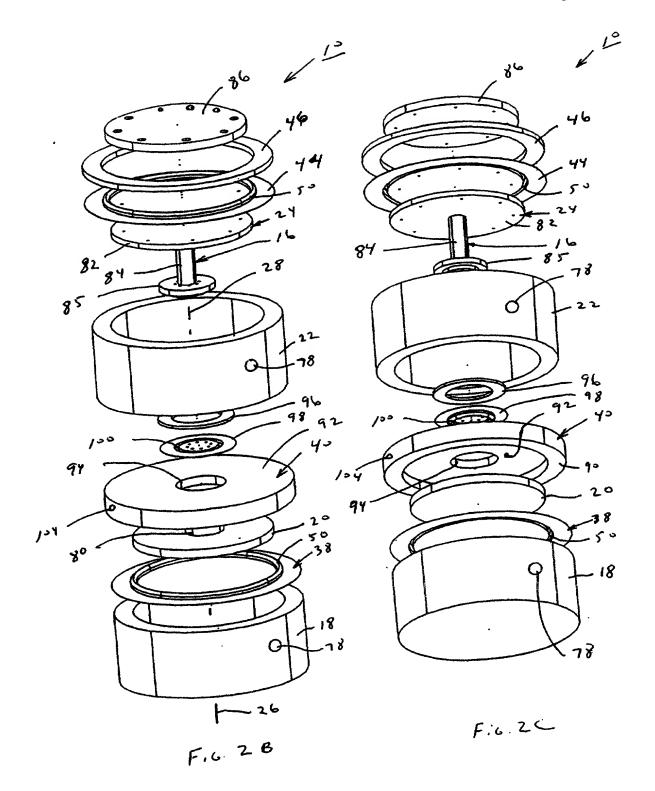
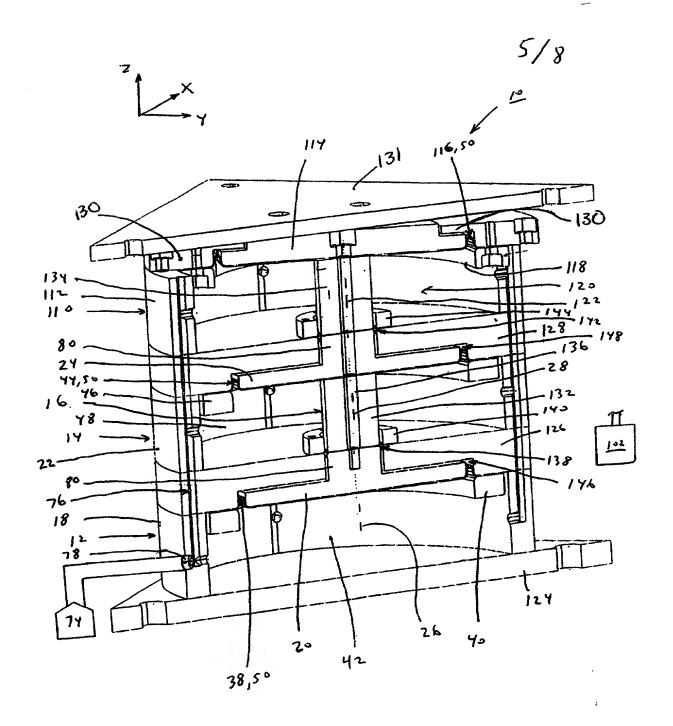
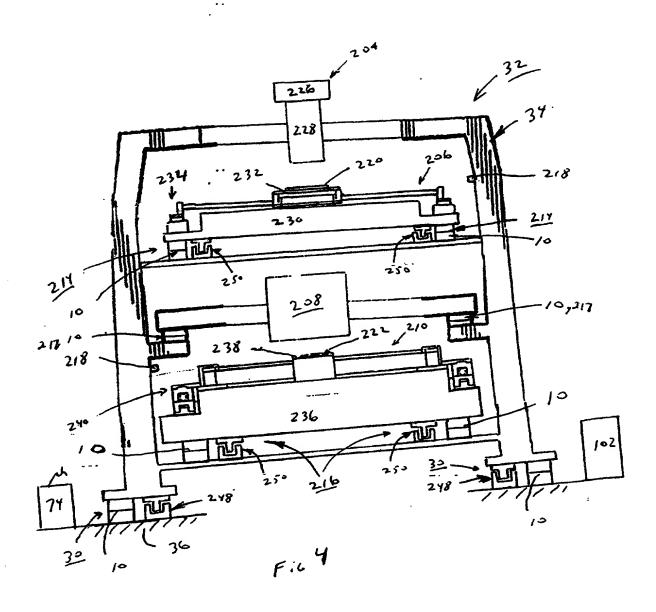


Fig. 2A





F.6 3



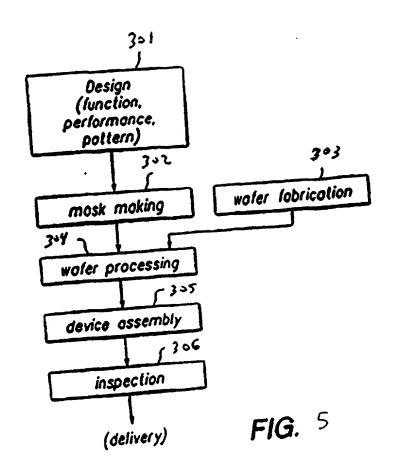


Fig. 6 317 Ion implantation 313 312 311 Electrode formation CVD Oxidation Preprocessing steps 315 Photoresist formation Post-processing steps Exposure 317 Developing 318 .Etching 315 Photoresist removal